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Suzuki et al.

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(54) **LINER FOR PLASMA PROCESSING APPARATUS**

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(52) **U.S. Cl.** **D15/138**

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156/345.46; 205/50; 216/67, 69, 70; 219/121.36,
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See application file for complete search history.

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(57) **CLAIM**

The ornamental design for a liner for plasma processing apparatus, as shown and described.

DESCRIPTION

FIG. 1 is a front view of a liner for plasma processing apparatus showing our new design;
FIG. 2 is a top plan view thereof;
FIG. 3 is a bottom plan view thereof;
FIG. 4 is a right side view thereof;
FIG. 5 is a sectional view taken along line 5-5 of FIG. 2 thereof; and,
FIG. 6 is a perspective view thereof.

1 Claim, 3 Drawing Sheets

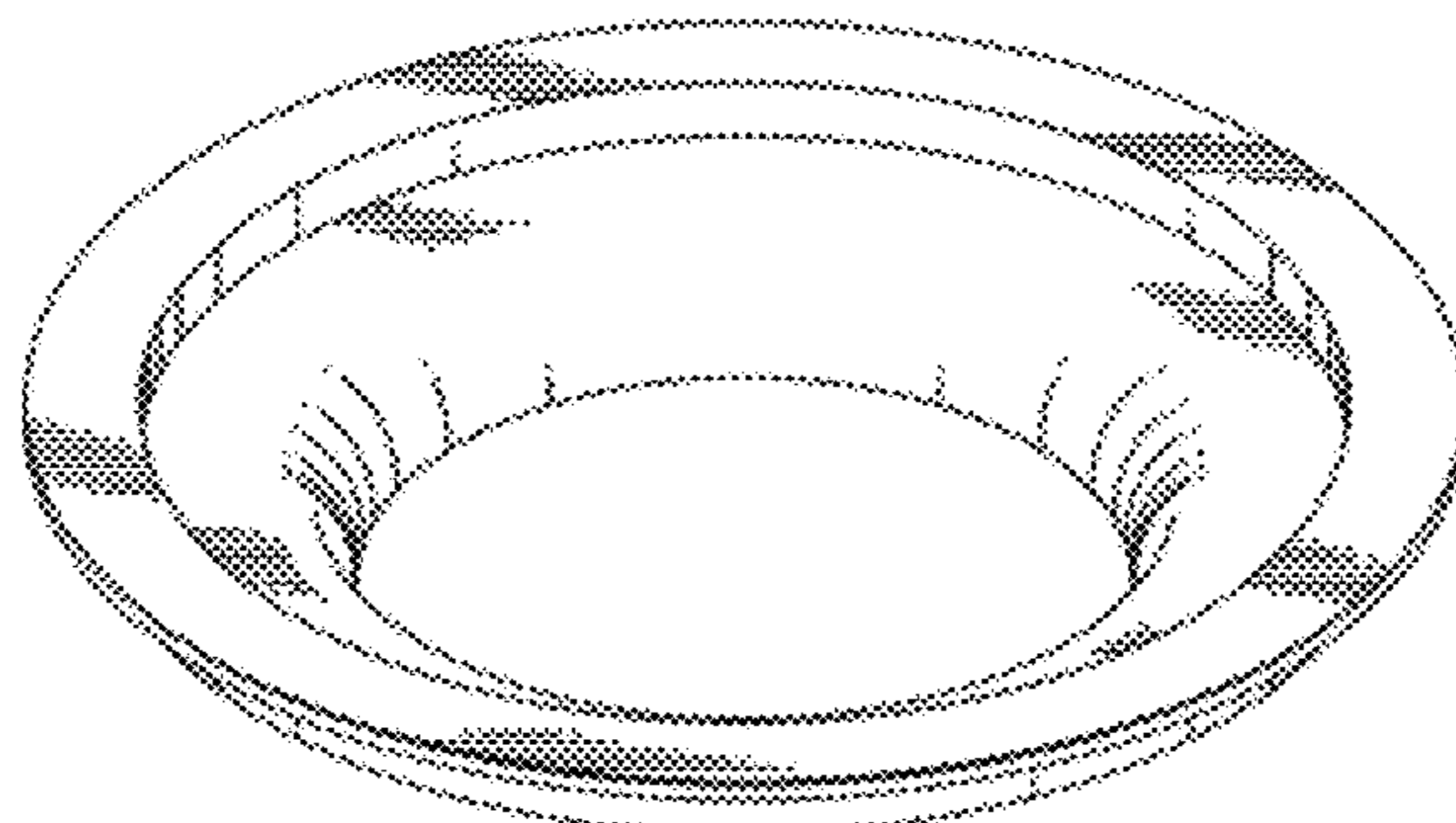


FIG. 1

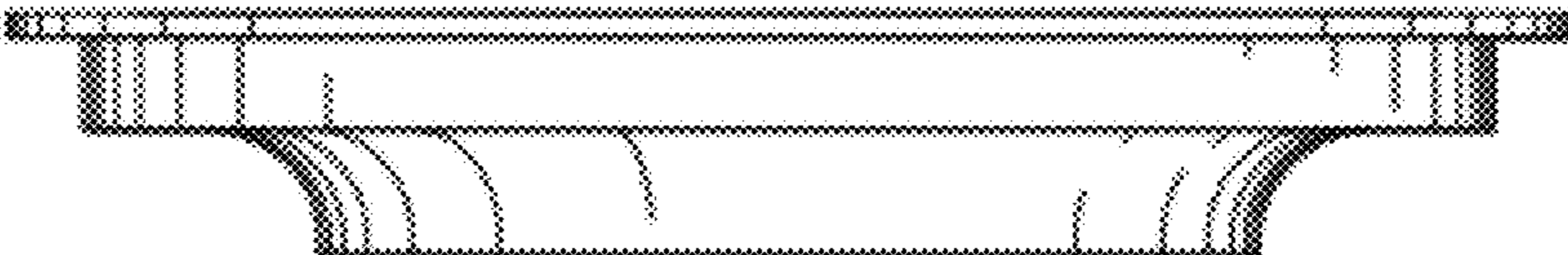


FIG. 2

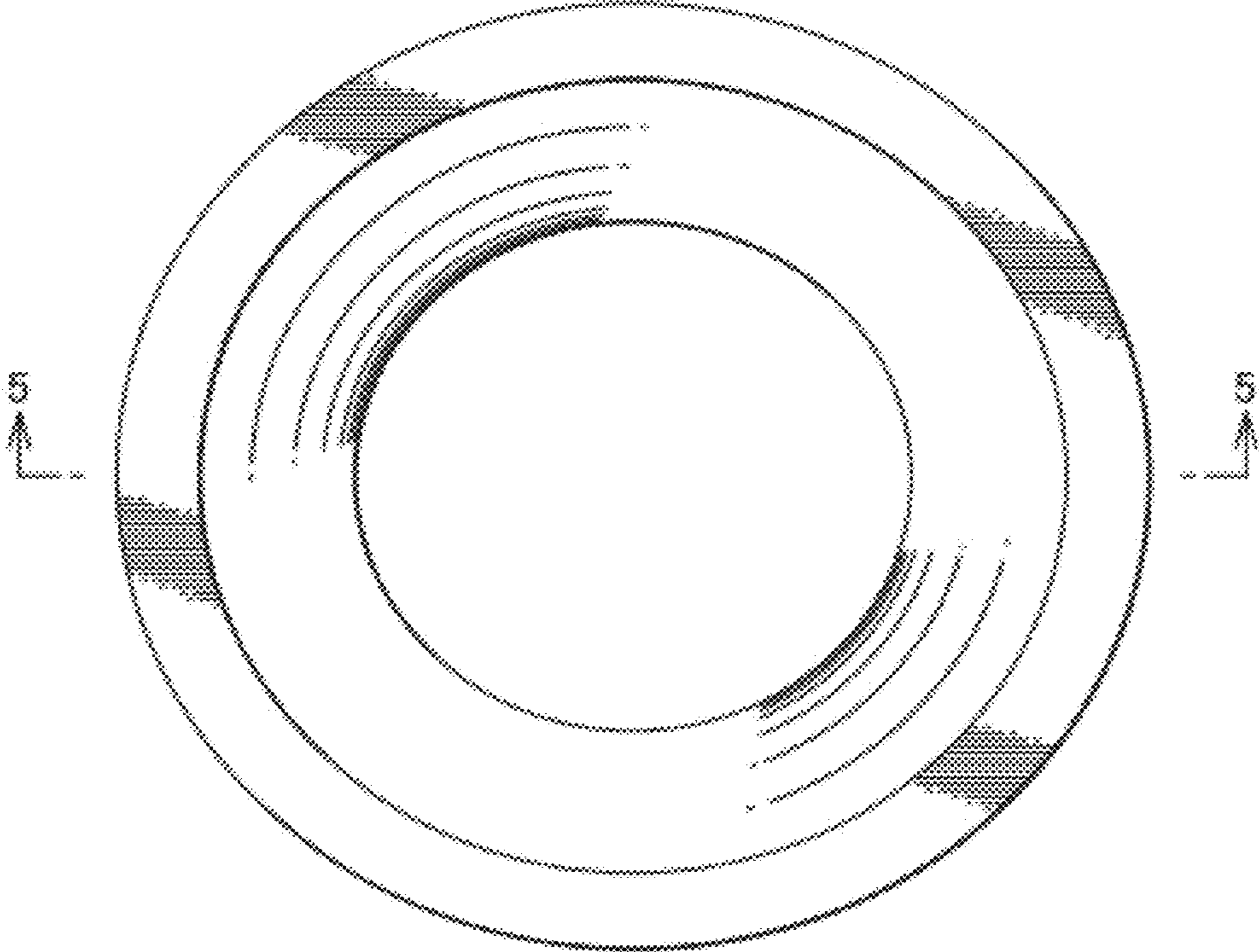


FIG.3

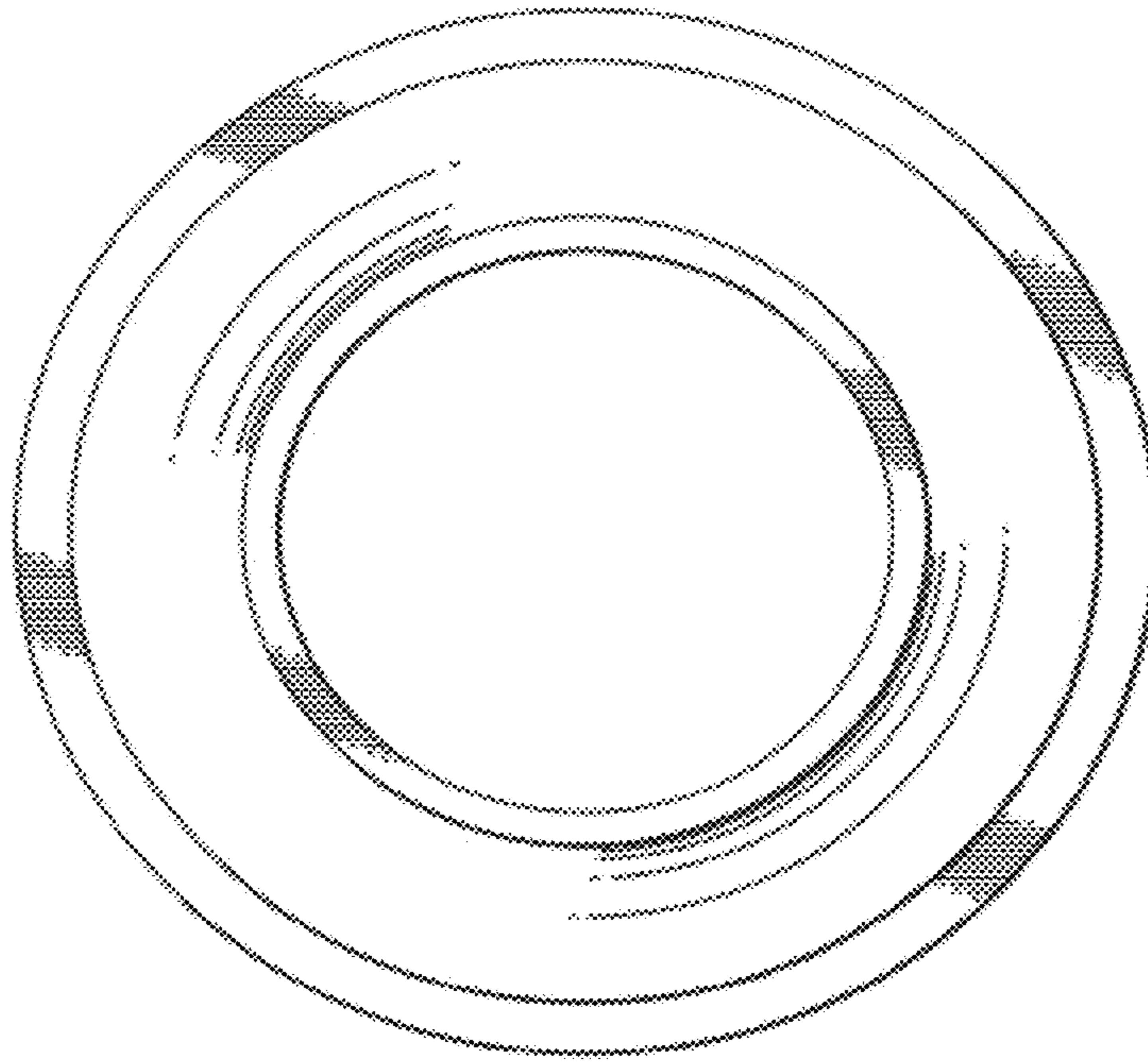


FIG.4

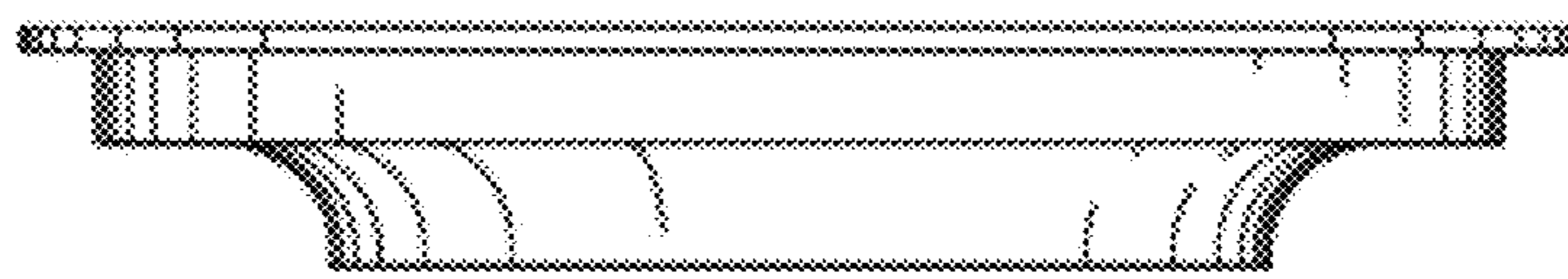


FIG.5

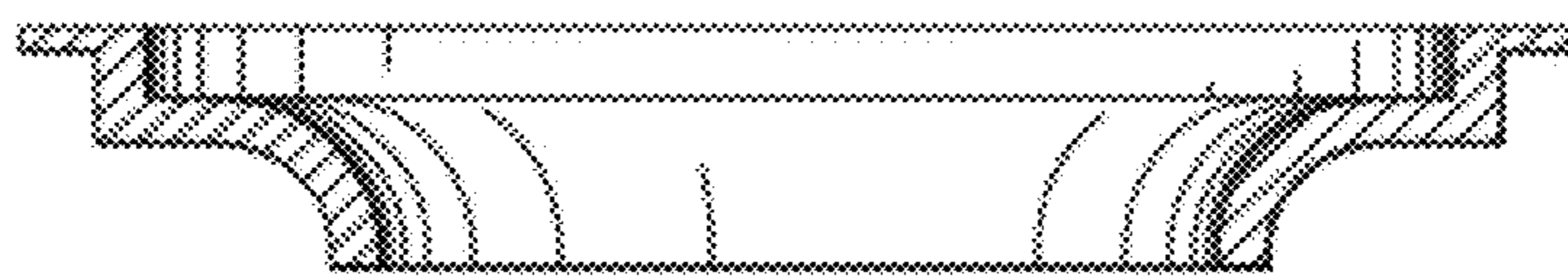


FIG.6

